

**IN THE CLAIMS:**

Please amend claims 1 and 4, and add new claims 12-17, as shown in the complete list of claims that is presented below.

1. (currently amended) A transflective liquid crystal display device, comprising:  
a first substrate and a second substrate opposite thereto;  
a first color filter on the first substrate;  
a second color filter on an inner side of the second substrate;  
a reflective electrode ~~on between the first and second color filters~~, wherein the reflective electrode has at least one opaque portion and at least one transparent portion ~~that are disposed between the first and second color filters, and wherein the at least one opaque portion has an uneven surface and the at least one transparent portion has an even surface;~~  
~~a second color filter on an inner side of the second substrate;~~  
a common electrode on the second color filter; and  
a liquid crystal layer between the first substrate and the second substrate.

2. (original) The transflective LCD device according to claim 1, further comprising:  
an insulating layer formed between the first color filter and the reflective electrode.

3. (original) The transflective LCD device according to claim 1, wherein the first substrate is a substrate comprising a thin film transistor (TFT) array.

4. (currently amended) The transflective LCD device according to claim 1, wherein the opaque portion of the reflective electrode is an aluminum layer having an uneven surface. layer.

5. (original) The transflective LCD device according to claim 1, wherein the transparent portion of the reflective electrode is an ITO (indium tin oxide) or IZO (indium zinc oxide) layer.

6. (original) The transflective LCD device according to claim 1, wherein partial surfaces of the first color filter have bumps.

7. (original) A transflective liquid crystal display device, comprising:  
a first substrate and a second substrate opposite thereto;  
a first color filter on the first substrate;  
a reflective layer on part of the first color filter;  
a second color filter on the reflective layer and the first color filter;  
a transparent electrode on the second color filter;  
a common electrode on an inner side of the second substrate; and  
a liquid crystal layer between the first substrate and the second substrate.

8. (original) The transflective LCD device according to claim 7, wherein the first substrate is a substrate comprising a thin film transistor (TFT) array.

9. (original) The transflective LCD device according to claim 7, wherein the reflective layer is an aluminum layer having an uneven surface.

10. (original) The transflective LCD device according to claim 7, wherein the transparent portion of the transparent electrode is an ITO (indium tin oxide) or IZO (indium zinc oxide) layer.

11. (original) The transflective LCD device according to claim 7, wherein partial surfaces of the first color filter have bumps.

12. (new) The transreflective LCD device according to claim 1, further comprising an insulating layer having a surface on which the reflective electrode is disposed, the surface of the insulating layer having at least one uneven portion and at least one even portion, and wherein the reflective layer comprises a metal layer on the surface of the insulating layer, the metal layer having at least one opening aligned with the at least one even portion of the insulating layer.

13. (new) A transreflective liquid crystal display device, comprising:  
a first substrate and a second substrate opposite thereto;  
a first color filter on the first substrate;  
an insulating layer formed on the first color filter;  
a reflective electrode on the insulating layer, wherein the reflective electrode has at least one opaque portion and at least one transparent portion;  
a second color filter on an inner side of the second substrate;  
a common electrode on the second color filter; and  
a liquid crystal layer between the first substrate and the second substrate.

14. (new) The transreflective LCD device according to claim 13, wherein the first substrate is a substrate comprising a thin film transistor (TFT) array.

15. (new) The transreflective LCD device according to claim 13, wherein the opaque portion of the reflective electrode is an aluminum layer.

16. (new) The transreflective LCD device according to claim 13, wherein the transparent portion of the reflective electrode is an ITO (indium tin oxide) or IZO (indium zinc oxide) layer.

17. (new) The transreflective LCD device according to claim 13, wherein partial surfaces of the first color filter have bumps.